

CONTINUATION-IN-PART OF USSN 10/040,663, FILED JANUARY 7, 2002

Application Based on

Docket **83075ANAB**

Inventors: Andrew F. Kurtz, Barry D. Silverstein, Xiang-Dong Mi

Customer No. 01333

**DISPLAY APPARATUS USING A WIRE GRID POLARIZING  
BEAMSPLITTER WITH COMPENSATOR**

Commissioner for Patents,  
ATTN: MAIL STOP PATENT APPLICATION  
P.O. Box 1450  
Alexandria, VA. 22313-1450

Express Mail Label No.: EV 293509916 US

Date: November 13, 2003

**DISPLAY APPARATUS USING A WIRE GRID POLARIZING  
BEAMSPLITTER WITH COMPENSATOR**

**CROSS REFERENCE TO RELATED APPLICATIONS**

This is a continuation-in-part of application Serial No. 10/040,663,  
5 filed January 7, 2002, entitled DISPLAY APPARATUS USING A WIRE GRID  
POLARIZING BEAMSPLITTER WITH COMPENSATOR, by Mi et al.

**FIELD OF THE INVENTION**

This invention generally relates to digital projection apparatus  
employing liquid crystal devices for image forming and more particularly to an  
10 apparatus and method for achieving high levels of contrast by using a wire grid  
polarization beamsplitter with a compensator for minimizing leakage light in the  
pixel black (OFF) state.

**BACKGROUND OF THE INVENTION**

In order to be considered as suitable replacements for conventional  
15 film projectors, digital projection systems must meet demanding requirements for  
image quality. This is particularly true for cinematic projection systems. To  
provide a competitive alternative to conventional cinematic-quality projectors,  
digital projection apparatus, provide high resolution, wide color gamut, high  
brightness (>10,000 screen lumens), and frame-sequential system contrast ratios  
20 exceeding 1,000:1.

The most promising solutions for digital cinema projection employ  
one of two types of spatial light modulators as image forming devices. The first  
type of spatial light modulator is the digital micromirror device (DMD),  
developed by Texas Instruments, Inc., Dallas, Texas. DMD devices are described  
25 in a number of patents, for example U.S. Patent Nos. 4,441,791; 5,535,047;  
5,600,383 (all to Hornbeck); and U.S. Patent No. 5,719,695 (Heimbuch). Optical  
designs for projection apparatus employing DMDs are disclosed in U.S. Patent  
Nos. 5,914,818 (Tejada et al.); 5,930,050 (Dewald); 6,008,951 (Anderson); and  
6,089,717 (Iwai). Although DMD-based projectors demonstrate some capability  
30 to provide the necessary light throughput, contrast ratio, and color gamut, current  
resolution limitations (1024 x 768 pixels) and high component and system costs  
have restricted DMD acceptability for high-quality digital cinema projection.

The second type of spatial light modulator used for digital projection is the liquid crystal device (LCD). The LCD forms an image as an array of pixels by selectively modulating the polarization state of incident light for each corresponding pixel. At high resolution, large area LCDs can be fabricated more readily than DMDs. LCDs are a viable alternative modulator technology to be used in digital cinema projection systems. Among examples of electronic projection apparatus that utilize LCD spatial light modulators are those disclosed in U.S. Patent Nos. 5,808,795 (Shimomura et al.); 5,798,819 (Hattori et al.); 5,918,961 (Ueda); 6,010,121 (Maki et al.); and 6,062,694 (Oikawa et al.). Recently, JVC demonstrated an LCD-based projector capable of high-resolution (providing 2,000 x 1280 pixels), high frame sequential contrast (in excess of 1000:1), and high light throughput (nominally, up to 12,000 lumens). This system utilized three vertically aligned (VA) (also referred as homeotropic) LCDs (one per color) driven or addressed by cathode ray tubes (CRTs). While this system demonstrated the potential for an LCD based digital cinema projector, system complexity and overall reliability remain concerns. In addition, cost considerations render such a system not yet ready for broad commercialization in the digital cinema projection market.

JVC has also developed a new family of vertically aligned LCDs, which are directly addressed via a silicon backplane (LCOS), rather than indirectly by a CRT. While these new devices are promising, they have not yet been demonstrated to fully meet the expectations for digital cinema presentation. The JVC LCD devices are described, in part, in U.S. Patents Nos. 5,652,667 (Kuragane); 5,767,827 (Kobayashi et al.); and 5,978,056 (Shintani et al.) In contrast to early twisted nematic or cholesteric LCDs, vertically aligned LCDs promise to provide much higher modulation contrast ratios (in excess of 2,000:1). U.S. Patent No. 5,620,755 (Smith et al.), also assigned to JVC, specifically describes a methodology for inducing vertical alignment in LC displays. It is instructive to note that, in order to obtain on screen frame sequential contrast of 1,000:1 or better, the entire system must produce >1000:1 contrast, and both the LCDs and any necessary polarization optics must each separately provide ~2,000:1 contrast. Notably, while polarization compensated vertically aligned

LCDs can provide contrast  $>20,000:1$  when modulating collimated laser beams, these same modulators may exhibit contrasts of  $500:1$  or less when modulating collimated laser beams without the appropriate polarization compensation.

Modulation contrast is also dependent on the spectral bandwidth and angular width (F#) of the incident light, with contrast generally dropping as the bandwidth is increased or the F# is decreased. Modulation contrast within LCDs can also be reduced by residual de-polarization or mis-orienting polarization effects, such as thermally induces stress birefringence. Such effects can be observed in the far field of the device, where the typically observed “iron cross” polarization contrast pattern takes on a degenerate pattern.

As is obvious to those skilled in the digital projection art, the optical performance provided by LCD based electronic projection system is, in large part, defined by the characteristics of the LCDs themselves and by the polarization optics that support LCD projection. The performance of polarization separation optics, such as polarization beamsplitters, pre-polarizers, and polarizer/analyzer components is of particular importance for obtaining high contrast ratios. The precise manner in which these polarization optical components are combined within a modulation optical system of a projection display can also have significant impact on the final resultant contrast.

The most common conventional polarization beamsplitter solution, which is used in many projection systems, is the traditional MacNeille prism, disclosed in U.S. Patent No. 2,403,731. This device has been shown to provide a good extinction ratio (on the order of  $300:1$ ). However, this standard prism operates well only with incident light over a limited range of angles (a few degrees). Because the MacNeille prism design provides good extinction ratio for one polarization state only, a design using this device must effectively discard half of the incoming light when this light is from an unpolarized white light source, such as from a xenon or metal halide arc lamp.

Conventional glass polarization beamsplitter design, based on the MacNeille design, has other limitations beyond the limited angular response, which could impede its use for digital cinema projection. In particular, bonding techniques used in fabrication or thermal stress in operation, can cause stress

birefringence, in turn degrading the polarization contrast performance of the beamsplitter. These effects, which are often unacceptable for mid range electronic projection applications, are not tolerable for cinema projection applications. The thermal stress problem has recently been improved upon, with the use of a more  
5 suitable low photo-elasticity optical glass, disclosed in U.S. Patent No. 5,969,861 (Ueda et al.), which was specially designed for use in polarization components. Unfortunately, high fabrication costs and uncertain availability limit the utility of this solution. Furthermore, while it would be feasible to custom melt low-stress glass prisms suited to each wavelength band in order to minimize stress  
10 birefringence, while somewhat expanding angular performance, such a solution is costly and error-prone. As a result of these problems, the conventional MacNeille based glass beamsplitter design, which is capable of the necessary performance for low to mid-range electronic projection systems, operating at 500-5,000 lumens with approximately 800:1 contrast, likely falls short of the more demanding  
15 requirements of full-scale commercial digital cinema projection.

Other polarization beamsplitter technologies have been proposed to meet the needs of an LCD based digital cinema projection system. For example, the beamsplitter disclosed in U.S. Patent No. 5,912,762 (Li et al.), which comprises a plurality of thin film layers sandwiched between two dove prisms,  
20 attempts to achieve high extinction ratios for both polarization states. Theoretically, this beamsplitter device is capable of extinction ratios in excess of 2,000:1. Moreover, when designed into a projection system with six LCDs (two per color), this prism could boost system light efficiency by allowing use of both polarizations. However, size constraints and extremely tight coating tolerances  
25 present significant obstacles to commercialization of a projection apparatus using this beamsplitter design.

As another conventional solution, some projector designs have employed liquid-immersion polarization beamsplitters. Liquid-filled beamsplitters (see U.S. Patent 5,844,722 (Stephens), for example) have been  
30 shown to provide high extinction ratios needed for high-contrast applications and have some advantages under high-intensity light conditions. However, these devices are costly to manufacture, must be fabricated without dust or contained

bubbles and, under conditions of steady use, have exhibited a number of inherent disadvantages. Among the disadvantages of liquid-immersion polarization beamsplitters are variations in refractive index of the liquid due to temperature, including uneven index distribution due to convection. Leakage risk presents  
5 another potential disadvantage for these devices.

Wire grid polarizers have been in existence for many years, and were primarily used in radio-frequency and far infrared optical applications. Use of wire grid polarizers with visible spectrum light has been limited, largely due to constraints of device performance or manufacture. For example, U.S. Patent No.  
10 5,383,053 (Hegg et al.) discloses use of a wire grid beamsplitter in a virtual image display apparatus. In the Hegg et al. disclosure, an inexpensive wire grid beamsplitter provides high light throughput efficiency when compared against conventional prism beamsplitters. The polarization contrast provided by the wire grid polarizer of Hegg et al. is very low (6.3:1) and unsuitable for digital  
15 projection. A second wire grid polarizer for the visible spectrum is disclosed in U.S. Patent No. 5,748,368 (Tamada). While the device discussed in this patent provides polarization separation, the contrast ratio is inadequate for cinematic projection and the design is inherently limited to rather narrow wavelength bands.

Recently, as is disclosed in U.S. Patent Nos. 6,122,103 (Perkins et  
20 al.); 6,243,199 (Hansen et al.); and 6,288,840 (Perkins et al.), high quality wire grid polarizers and beamsplitters have been developed for broadband use in the visible spectrum. These new devices are commercially available from Moxtek Inc. of Orem, UT. While existing wire grid polarizers, including the devices described in U.S. Patent Nos. 6,122,103 and 6,243,199 may not exhibit all of the  
25 necessary performance characteristics needed for obtaining the high contrast required for digital cinema projection, these devices do have a number of advantages. When compared against standard polarizers, wire grid polarization devices exhibit relatively high extinction ratios and high efficiency. Additionally, the contrast performance of these wire grid devices also has broader angular  
30 acceptance (NA or numerical aperture) and more robust thermal performance with less opportunity for thermally induced stress birefringence than standard polarization devices. Furthermore, the wire grid polarizers are robust relative to

harsh environmental conditions, such as light intensity, temperature, and vibration. These devices perform well under conditions of different color channels, with the exception that response within the blue light channel may require additional compensation.

5                   Wire grid polarization beamsplitter (PBS) devices have been employed within some digital projection apparatus. For example, U.S. Patent No. 6,243,199 (Hansen et al.) discloses use of a broadband wire grid polarizing beamsplitter for projection display applications. U.S. Patent No. 6,234,634 (also to Hansen et al.) discloses a wire grid polarizing beamsplitter that functions as  
10 both polarizer and analyzer in a digital image projection system. U.S. Patent No. 6,234,634 states that very low effective  $F\#$ 's can be achieved using wire grid PBS, with some loss of contrast, however. Notably, U.S. Patent No. 6,234,634 does not discuss how polarization compensation may be used in combination with wire grid devices to reduce light leakage and boost contrast for fast optical  
15 systems operating at low  $F\#$ 's.

                  In general, wire grid polarizers have not yet been satisfactorily proven to meet all of the demanding requirements imposed by digital cinema projection apparatus, although progress is being made. Deficiencies in substrate flatness, in overall polarization performance, and in robustness at both room  
20 ambient and high load conditions have limited commercialization of wire grid polarization devices for cinematic projection.

                  Of particular interest and relevance for the apparatus and methods of the present invention, it must be emphasized that individually neither the wire grid polarizer, nor the wire grid polarization beamsplitter, provide the target  
25 polarization extinction ratio performance (nominally  $>2,000:1$ ) needed to achieve the desired projection system frame sequential contrast of  $1,000:1$  or better, particularly at small  $F\#$ 's ( $< F/3.5$ ). Rather, both of these components provide less than  $\sim 1,200:1$  contrast under the best conditions. Significantly, performance falls off further in the blue spectrum. Therefore, to achieve the desired  $2,000:1$  contrast  
30 target for the optical portion of the system (excluding the LCDs), it is necessary to utilize a variety of polarization devices, including possibly wire grid polarization devices, in combination within a modulation optical system of the projection

display. However, the issues of designing an optimized configuration of polarization optics, including wire grid polarizers, in combination with the LCDs, color optics, and projection lens, have not been completely addressed either for electronic projection in general, or for digital cinema projection in particular.

- 5 Moreover, the prior art does not describe how to design a modulation optical system for a projection display using both LCDs and wire grid devices, which further has polarization compensators to boost contrast.

There are numerous examples of polarization compensators developed to enhance the polarization performance of LCDs generally, and  
10 vertically aligned LCDs particularly. In an optimized system, the compensators are simultaneously designed to enhance the performance of the LCDs and the polarization optics in combination. These compensators typically provide angular varying birefringence, structured in a spatially variant fashion, to affect polarization states in portions (within certain spatial and angular areas) of the  
15 transiting light beam, without affecting the polarization states in other portions of the light beam. Polarization compensators have been designed to work with LCDs generally, but also vertically aligned LCDs in particular. U.S. Patent No. 4,701,028 (Clerc et al.) discloses birefringence compensation designed for a vertically aligned LCD with restricted thickness. U.S. Patent No. 5,039,185  
20 (Uchida et al.) discloses a vertically aligned LCD with compensator comprising at least two uniaxial or two biaxial retarders provided between a sheet polarizer/analyzer pair. U.S. Patent No. 5,298,199 (Hirose et al.) discloses the use of a biaxial film compensator correcting for optical birefringence errors in the LCD, used in a package with crossed sheet polarizers, where the LCD dark state  
25 has a non-zero voltage (a bias voltage). U.S. Patent No. 6,081,312 (Aminaka et al.) discloses a discotic film compensator which is designed to optimize contrast for a voltage ON state of the VA LCD. By comparison, U.S. Patent No. 6,141,075 (Ohmuro et al.) discloses a VA LCD compensated by two retardation films, one with positive birefringence and the other with negative birefringence.  
30 U.S. Patent No. 5,576,854 (Schmidt et al.) discloses a compensator constructed for use in projector apparatus using an LCD with the conventional MacNeille prism type polarization beamsplitter. This compensator comprises a  $\frac{1}{4}$



wave plate for compensating the prism and an additional  $0.02 \lambda$ 's compensation for the inherent LCD residual birefringence effects. U.S. Patent No. 5,619,352 (Koch et al.) discloses compensation devices, usable with twisted nematic LCDs, where the compensators have a multi-layer construction, using combinations of A-plates, C-plates, and O-plates, as needed.

In general, most of these prior art compensator patents assume the LCDs are used in combination with sheet polarizers, and correct for the LCD polarization errors. However, polarization compensators have also been explicitly developed to correct for non-uniform polarization effects from the conventional Polaroid type dye sheet polarizer. The dye sheet polarizer, developed by E. H. Land in 1929 functions by dichroism, or the polarization selective anisotropic absorption of light. Compensators for dye sheet polarizers are described in Chen et al. (J. Chen, K.-H. Kim, J.-J. Kyu, J. H. Souk, J.R. Kelly, P.J. Bos, "Optimum Film Compensation Modes for TN and VA LCDs", SID 98 Digest, pgs. 315-318.), and use a combination A-plate and C-plate construction. The maximum contrast of the LCD system aimed at in prior art patents such as in U.S. Patent No. 6,141,075 (Ohmuro et al.) is only up to 500:1, which is sufficient for many applications, but does not meet the requirement of digital cinema projection.

While this prior art material extensively details the design of polarization compensators used under various conditions, compensators explicitly developed and optimized for use with wire grid polarizers are not disclosed. Furthermore, the design of polarization compensators to enhance the performance of a modulation optical system using multiple wire grid polarizer devices, or using multiple wire grid devices in combination with vertically aligned LCDs, have not been previously disclosed. Without compensation, the wire grid polarization beamsplitter provides acceptable contrast when incident light is within a low numerical aperture. However, in order to achieve high brightness levels, it is most advantageous for an optical system to have a high numerical aperture ( $> \sim 0.13$ ), so that it is able to gather incident light at larger oblique angles. The conflicting goals of maintaining high brightness and high contrast ratio present a significant design problem for polarization components. Light leakage in the OFF state must be minimal in order to achieve high contrast levels. Yet, light leakage is most

pronounced for incident light at the oblique angles required for achieving high brightness.

Compensator requirements for wire grid polarizing beamsplitter devices differ significantly from more conventional use of compensators with  
5 polarizing beamsplitter devices based on the MacNeille prism design as was noted in reference to U.S. Patent No. 5,576,854. Performance results indicate that the conventional use of a  $\frac{1}{4}$  wave plate compensator is not a solution and can even degrade contrast ratio. Additionally, while compensators have previously been specifically developed to work in tandem with VA LCDs in projection display  
10 systems, compensators optimized for use with VA LCDs in the context of a modulation optical system which utilizes wire grid polarization beamsplitters have not been developed and disclosed.

Thus it can be seen that there is a need for an improved projection apparatus that uses wire grid polarization devices, vertically aligned LCDs, and  
15 polarization compensators in combination to provide high-contrast output.

### **SUMMARY OF THE INVENTION**

Briefly, according to one aspect of the present invention a modulation optical system for providing modulation of an incident light beam comprises a wire grid polarization beamsplitter for receiving the beam of light, for  
20 transmitting light from the beam of light having a first polarization, and for reflecting light of the beam of light having a second polarization orthogonal to the first polarization, wherein sub-wavelength wires on the wire grid polarization beamsplitter face a reflective spatial light modulator. The reflective spatial light modulator receives the polarized beam of light, having either a first polarization or  
25 a second polarization, and selectively modulates the polarized beam of light to encode data thereon, providing both modulated light and unmodulated light which differ in polarization. The reflective spatial light modulator reflects back both the modulated light and the unmodulated light to the wire grid polarization beamsplitter. The wire grid polarization beamsplitter then separates the  
30 modulated light from the unmodulated light. A compensator is located between the wire grid polarization beamsplitter and the reflective spatial light modulator, wherein the compensator is provided for conditioning the polarization states of the

oblique and skew rays of the modulated beam. The compensator includes a spatially variant retardance that corrects for a spatially variant retardance of the reflective spatial light modulator.

5 The invention and its objects and advantages will become more apparent in the detailed description of the preferred embodiment presented below.

### **BRIEF DESCRIPTION OF THE DRAWINGS**

While the specification concludes with claims particularly pointing out and distinctly claiming the subject matter of the present invention, it is believed that the invention will be better understood from the following  
10 description when taken in conjunction with the accompanying drawings, wherein:

Figure 1 is a schematic view showing an arrangement of optical components in a projection apparatus;

Figure 2 is a perspective view of a prior art wire grid polarizer.

Figure 3 is a cross sectional view showing a modulation optical  
15 system which includes a wire grid polarization beamsplitter.

Figure 4 is a graph showing the relationship of contrast ratio to  $F/\#$  for a modulation optical system which includes both a wire grid polarization beamsplitter and an LCD, both with and without polarization compensation.

Figure 5a shows the geometry of incident light relative to the wire  
20 grid polarizing beamsplitter and an LCD within a modulation optical system, illustrating both polarization states and the local beam geometry.

Figure 5b illustrates the geometry of normally incident light relative to the polarization states of crossed polarizers.

Figure 5c illustrates the geometry of an unfolded modulation  
25 optical system with a transmissive spatial light modulator, wire grid polarizers, and a polarization compensator.

Figures 6a and 6b show the angular response for crossed wire grid polarizers without polarization compensation.

Figures 7a-e show the possible axial orientations and construction  
30 of a polarization compensator.

Figures 8a-i are the far field angular response plots from various arrangements of wire grid polarization devices and compensators.

Figure 9a shows the contrast contour plot for an ideal VA LCD without compensator.

Figure 9b shows the contrast contour plot for a VA LCD with 10nm induced retardation from ITO substrate.

5                    Figure 9c shows the contrast contour plot for a VA LCD with 10nm induced retardation from ITO substrate and with proper compensator.

Figure 10 is a schematic view showing the basic components of a modulation optical system according to the preferred embodiment of the present invention.

10                   Figure 11 shows a contrast pattern with a high contrast ratio in the center.

Figure 12 shows a schematic side view of a patterned compensator according to the present invention.

#### **DETAILED DESCRIPTION OF THE INVENTION**

15                   The present description is directed in particular to elements forming part of, or cooperating more directly with, apparatus in accordance with the invention. It is to be understood that elements not specifically shown or described may take various forms well known to those skilled in the art.

Referring to Figure 1, there is shown in schematic form the  
20 arrangement of optical components in a digital projection apparatus 10, as described in commonly-assigned U.S. Patent No. 6,585,378 (Kurtz et al.), the disclosure of which is incorporated herein. Illumination optics 20 and pre-polarizer 45 precondition light from a light source 15 to provide illumination that is essentially uniformized and polarized. Illumination optics 20 includes  
25 uniformizing optics, such as an integrating bar or a fly's eye integrator assembly, and condensing relay optics assembly. This light is subsequently polarized by pre-polarizer 45, with light of the desired polarization state directed towards the polarization beamsplitter, while the rejected alternate polarization state light nominally reflects back towards the light source. Pre-polarizer 45 is part of  
30 modulation optical system 40, which also comprises a wire grid polarization beamsplitter 50, a polarization rotating spatial light modulator 55, and a polarization analyzer 60. Nominally, wire grid polarization beamsplitter 50

transmits the incident light having the preferred polarization state, while reflecting residual incident light having the alternate polarization state out of the system. Incident light is modulated by spatial light modulator 55, which is nominally a liquid crystal display (LCD), to encode a two-dimensional image onto the light, which is then reflected as a modulated light beam. Wire grid polarization beamsplitter 50 reflects light from the modulated light beam having one polarization state, and transmits the light having the alternate polarization state. Projection optics 70 then directs the reflected modulated light beam onto a display surface 75, which is nominally a projection screen.

10                   The design of digital projection apparatus 10 and modulation optical system 40 both can be better understood from a deeper discussion of the properties of the wire grid polarizers used within these systems. Figure 2 illustrates a basic prior art wire grid polarizer and defines terms that will be used in a series of illustrative examples of the prior art and the present invention. The wire grid polarizer 100 is comprised of a multiplicity of parallel conductive electrodes (wires) 110 supported by a dielectric substrate 120. This device is characterized by the grating spacing or pitch or period of the conductors, designated (p); the width of the individual conductors, designated (w); and the thickness of the conductors, designated (t). Nominally, a wire grid polarizer uses sub-wavelength structures, such that the pitch (p), conductor or wire width (w), and the conductor or wire thickness (t) are all less than the wavelength of incident light ( $\lambda$ ). A beam of light 130 produced by a light source 132 is incident on the polarizer at an angle  $\theta$  from normal, with the plane of incidence orthogonal to the conductive elements. The wire grid polarizer 100 divides this beam into specular non-diffracted outgoing light beams; reflected light beam 140 and transmitted light beam 150. The definitions for S and P polarization used are that S polarized light is light with its polarization vector parallel to the conductive elements, while P polarized light has its polarization vector orthogonal to the conductive elements. In general, a wire grid polarizer will reflect light with its electric field vector parallel ("S" polarization) to the grid, and transmit light with its electric field vector perpendicular ("P" polarization) to the grid. Wire grid polarizer 100 is a somewhat unusual polarization device, in that it is an E-type polarizer in

transmission (transmits the extraordinary ray) and O-type polarizer in reflection (reflects the ordinary ray).

When such a device is used at normal incidence ( $\theta=0$  degrees), the reflected light beam 140 is generally redirected towards the light source 132, and the device is referred to as a polarizer. However, when such a device is used at non-normal incidence (typically  $30^\circ < \theta < 60^\circ$ ), the illuminating beam of light 130, the reflected light beam 140, and the transmitted light beam 150 follow distinct separable paths, and the device is referred to as a polarization beamsplitter. The detailed design of a wire grid device, relative to wire pitch ( $p$ ), wire width ( $w$ ), wire duty cycle ( $w/p$ ), and wire thickness ( $t$ ), may be optimized differently for use as a polarizer or a polarization beamsplitter. It should be understood that both digital projection apparatus 10 and modulation optical system 40, when designed with polarization modifying spatial light modulators, may use polarization analyzers and polarization beamsplitters other than wire grid type devices. For example, the polarization beamsplitter may be a MacNeille type glass prism, or the polarizer may be either a dye/polymer based sheet polarizer. Within this discussion, the polarizing beamsplitter is assumed to be a wire grid type device, while both the pre-polarizer 45 and analyzer 60 are also generally considered to be wire grid devices as well, although that is not required for all configurations for the projector.

The preferred spatial relationships of these polarizers, as used in a modulation optical system 200, are illustrated in Figure 3. The basic structure and operation of modulation optical system 200 are described in commonly-assigned U.S. Patent No. 6,585,378, the disclosure of which is incorporated herein. Modulation optical system 200, which is a portion of an electronic projection system, comprises an incoming illumination light beam 220, focused through pre-polarizer 230, wire grid polarization beamsplitter 240, a compensator 260, and onto spatial light modulator 210 (the LCD) by a condensor 225. A modulated, image-bearing light beam 290 is reflected from the surface of spatial light modulator 210, transmitted through compensator 260, reflected off the near surface of wire grid polarization beamsplitter 240, and is subsequently transmitted through a polarization analyzer 270. After leaving modulation optical system 200,

modulation image bearing light beam 290 follows along optical axis 275, and is transmitted through recombination prism 280 and projection lens 285 on its way to the screen. Pre-polarizer 230 and polarization analyzer are assumed to both be wire grid polarization devices. A full color projection system would employ one  
5 modulation optical system 200 per color (red, green, and blue), with the color beams re-assembled through the recombination prism 280. Condensor 225, which will likely comprise several lens elements, is part of a more extensive illumination system which transforms the source light into a rectangularly shaped region of nominally uniform light which nominally fills the active area of spatial light  
10 modulator 210.

In a modulation optical system 200 utilizing a prior art wire grid polarization beamsplitter, the wire grid polarization beamsplitter 240 consists of a dielectric substrate 245 with sub-wavelength wires 250 located on one surface (the scale of the wires is greatly exaggerated). Wire grid polarization beamsplitter 240  
15 is disposed for reflection into projection lens system 285, thereby avoiding the astigmatism and coma aberrations induced by transmission through a tilted plate. Compensator 260 is nominally a waveplate which provides a small amount of retardance needed to compensate for geometrical imperfections and birefringence effects which originate at the surface of spatial light modulator 210. For example,  
20 as discussed in U.S. Patent 5,576,854 (Schmidt et al), compensator 260 may provide  $0.02 \lambda$ 's of retardance (A-plate) to correct for polarization errors caused by residual geometrical imperfections of the LCD polarizing layer and residual thermally induced birefringence within the counter electrode substrate within the LCD package. In less demanding applications than digital cinema, compensator  
25 260 may prove optional.

The construction of modulation optical system 200, as used in a digital cinema application, is defined both by the system specifications and the limitations of the available wire grid polarizing devices. In particular, digital cinema requires the electronic projector to provide high frame sequential system  
30 contrast (1,000:1 or better). To accomplish this, the polarization optical components, excluding spatial light modulator 210 (the LCD) of modulation optical system 200 must provide a total optical system contrast (Cs) of  $\sim 2,000:1$ .

The actual target contrast for the polarization optics does depend on the performance of the LCDs. Thus, if for example, the LCDs provide only ~1500:1 contrast, then the polarization optics must provide ~3,000:1 contrast. For example, an LCD with vertically aligned molecules is preferred for the digital  
5 cinema application due to its high innate contrast. Notably, the contrast performance of both the LCDs and the polarization optics typically decrease with increasing numerical aperture of the incident beam. Unfortunately, with today's technologies it is not sufficient to use just a single wire grid polarization beamsplitter 240 by itself in order to meet the 2,000:1 target contrast for the  
10 polarization optics. For this reason, modulation optical system 200 also uses a wire grid pre-polarizer 230 and a wire grid polarization analyzer 270 to provide the target polarization performance.

The construction and operation of modulation optical system 200 can be understood in yet greater detail, relative to its polarization performance.  
15 Preferably, pre-polarizer 230 is oriented to transmit "P" polarized light into the modulation optical system. Wire grid polarization beamsplitter 240 is oriented with its sub-wavelength wire pattern oriented nominally parallel to the sub-wavelength wires of polarizer 230 (that is, the two devices are not crossed). Thus, the transmitted "P" light is further modified (contrast enhanced) by transmission  
20 through the wire grid polarization beamsplitter. The transmitted light beam then passes through compensator 260 and encounters spatial light modulator 210, which is nominally a reflective LCD, which modifies the polarization state of the incident light on a pixel to pixel basis according to the applied control voltages. Intermediate code values, between white and black, reduce the amount of "On"  
25 state and increase the amount of "Off" state light. The "On" state light, which has been polarization rotated, is in the "S" polarization state relative to the wire grid beamsplitter 240. Thus the "S" state light reflects off the wire grid polarization beamsplitter 240, is subsequently transmitted through an optional compensator 265 (see Figures 5a and 10) and polarization analyzer 270, and directed to the  
30 screen by a projection lens 285. The overall contrast (Cs) for modulation optical system 200 (ignoring the LCD and compensator contributions) can be approximated by :



$$1/C_s = 1/(C_{T1} * C_{T2}) + 1/(C_{R2} * C_{T3}) ,$$

where  $C_{T1}$  is the transmitted contrast of the wire grid pre-polarizer 230,  $C_{T2}$  and  $C_{R2}$  are transmitted and reflected contrast ratios for the wire grid polarization beamsplitter 240, and  $C_{T3}$  is the transmitted contrast for the wire grid polarization analyzer 270. In this system, the overall contrast is largely determined by the low reflected contrast ratio  $C_{R2}$  for “S” polarization state light off of wire grid polarization beamsplitter 240. The analyzer contrast  $C_{T3}$  needs to be quite high to compensate for the low  $C_{R2}$  values (~30:1). Whereas the transmitted contrasts  $C_{T1}$  and  $C_{T2}$  do not need to be particularly high, provided that the respective contrast values are reasonably uniform over the spectrum. Polarization analyzer 270 is oriented so that the “On” state light, which reflects off the wire grid polarization beamsplitter 240 and has “S” polarization relative to the wire grid polarization beamsplitter 240, sees this same light as “P” state light relative to its own structure. Polarization analyzer 270 therefore removes any alternate polarization leakage light accompanying the desired “On” state beam.

As an example, in green light at 550 nm, wire grid pre-polarizer 230 has an angle averaged polarization contrast ratio of ~250:1. When used in combination, wire grid polarization beamsplitter 240 and wire grid pre-polarizer 230 produce an on screen frame sequential optical contrast ratio of ~25:1, which falls way short of the system requirements. Thus, the polarization performance of overall modulation optical system 200 is also supported with the addition of wire grid polarization analyzer 270, which is nominally assumed to be identical to wire grid polarizer 230. Polarization analyzer 270 removes the leakage of light that is of other than the preferred polarization state, boosting the theoretical overall system contrast  $C_s$  to ~2900:1. Performance does vary considerably across the visible spectrum, with the same combination of wire grid polarizing devices providing ~3400:1 contrast in the red spectrum, but only ~900:1 contrast in the blue. Certainly, this performance variation could be reduced with the use of color band tuned devices, if they were available.

Modulation optical system 200 is best constructed with wire grid polarization beamsplitter 240 oriented with the surface with the sub-wavelength wires 250 facing towards the spatial light modulator 210, rather than towards the

illumination optics (condensor 225) and light source (see Figure 3). While the overall contrast (Cs) is  $\sim 2,900:1$  when this orientation is used, the net contrast drops precipitously to  $\sim 250:1$  when the alternate orientation (wires on the surface towards the light source) is used. This difference in overall contrast when modulation optical system 200 is constructed with the image light reflecting off the wire grid polarization beamsplitter 240, as a function of whether the sub-wavelength wires 250 face the spatial light modulator or the light source, may be less important for slower (larger f#) systems. Additionally, referring to Figure 3, modulation optical system 200 provides the highest contrast and light efficiency when the sub-wavelength wires 250 of wire grid polarization beamsplitter 240 are oriented “vertically” (“into the page”, as shown), rather than “horizontally” (within the plane of the page). Wire grid polarization beamsplitter 240 can also be rotated (about the surface normal) by a few degrees to tune the contrast performance.

In order to build a digital cinema projector it is necessary to simultaneously maximize luminance (10,000-15,000 lumens) and contrast ( $1,000:1+$ ) with a system illuminating 35-55 ft. wide screens, while dealing with the limitations of the various optics, wire grid devices and LCDs. Luminance can be maximized by increasing the acceptance angle (numerical aperture) of light incident at the wire grid polarization beamsplitter and the LCD. With a wider acceptance angle (or a lower F#), the projection optics are able to gather more light. However, at the same time, the wider the angle of source light incident at wire grid polarization beamsplitter, the larger the leakage light from other polarization states and thus the smaller the contrast ratio (CR) available.

Referring to Figure 4, there is shown a graph of contrast for modulation optical system 200 (including wire grid pre-polarizer 230, wire grid polarization beamsplitter 240, a VA LCD, and a wire grid polarization analyzer 270) vs. the F# of the light transmitted through the system. The plot of system contrast 300 shows that at approximately  $F/2.3$ , a contrast ratio of  $\sim 600:1$  is achieved. This value is significantly less than the  $1,000:1+$  contrast needed for digital cinema projection. However, efficiency calculations suggest that an LCD based digital cinema projector will need to operate below  $F/3.0$  to meet the screen luminance

targets, with systems speeds of F/2.0 to F/2.3 being potentially required for the larger screens.

Referring to Figure 5a, there is shown a perspective view representing light polarization states for light reflected by and transmitted through wire grid polarization beamsplitter 240 within a modulation optical system, for a pixel of LCD 210. A collimated or specular pre-polarized beam 350 is transmitted through wire grid polarization beamsplitter 240. As shown in Figure 5a, the electric field polarization of transmitted beam 355 is on a vector perpendicular to the wire grid of wire grid polarization beamsplitter 240. A returning modulated beam 360 is reflected from the pixel on LCD 210, where the "S" polarized light is the image data, and the "P" polarized light is to be rejected. Ideally, wire grid polarization beamsplitter 240 transmits 100% of the unwanted "p" light as a modulated transmitted light 370. However, a small leakage light 365 is reflected from wire grid polarization beamsplitter 240 and accompanies "s" modulated beam 360, causing reduced contrast (ratio of "s" to "p"). Relative to the modulated beam 360, wire grid beamsplitter acts as a pre-polarizer in transmission and a polarization analyzer in reflection, comprising the typical crossed polarizer configuration.

While some loss of polarization contrast does occur with on axis collimated light, the effects are more dramatic for oblique and skew rays. To better understand this, Figure 5a includes an illustration of the beam geometry for a large NA non-specular beam incident on a 45° tilted surface of wire grid polarization beamsplitter 240, while Figure 5b shows the geometry for a beam incident normal to a surface (such as the LCD 210, pre-polarizer 230 or analyzer 270). For the normally incident case, the incoming beam is described by an azimuthal sweep of 0-180°, while the polar sweep of angles is limited (0-15° for F/2.0). The oblique rays are those rays that fall in the four quadrants outside the axes (azimuthal angles 0° and 180°, 90° and 270°) defined by the crossed polarizers, and which lie in planes which contain the local optical axis 275. The skew rays are the rays that lie in planes that do not contain the local optical axis 275. For the case of incidence to the 45° tilted surface, the incoming beam is again defined by an azimuthal sweep of 0-180°, while the polar sweep of angles

covers  $\sim 0\text{-}15^\circ$  relative to the optical axis, or a sweep of  $\sim 30\text{-}60^\circ$  relative to the wire grid surface. This beam geometry will be important in appreciating the results given by Figure 8a-i.

Figure 6a illustrates the polarization contrast profile for crossed  
5 polarizers, visible in angular space, and known as the “iron cross”. The iron cross pattern 320 demonstrates peak extinction in directions parallel and perpendicular to the grid of the analyzer, and diminished extinction for the skew rays and oblique rays in the four off-axis quadrants. As the wire grid polarization beamsplitter has superior angular performance when compared to most existing  
10 polarizers, these devices have been generally considered to not have a skew ray problem, and therefore to not require further polarization compensation. This is in part because the wire grid polarization beams splitter functions as an O-type polarizer in reflection and an E-type polarizer in transmission, and therefore is partially self compensating when used in both transmission and reflection as in  
15 modulation optical system 200. However, even so, the extinction of the wire grid polarization beamsplitter is still not adequate for demanding applications like digital cinema.

In the original electronic projection systems that were developed utilizing reflective liquid crystal displays, each LCD was addressed from behind  
20 using a CRT. Today, state of the art reflective LCDs are directly electronically addressed by means of a silicon backplane. These modern devices, which are known as liquid crystal on silicon (LCOS) displays, generally comprise a silicon substrate, which is patterned with pixel addressing circuitry, over coated with reflective and light blocking layers, followed by an LCD alignment layer, a thin  
25 ( $\sim 5\text{ }\mu\text{m}$ ) layer of liquid crystal, and an anti-reflection (AR) coated cover glass. The inside surface of the cover glass for a VA LCD has an ITO electrode addressing layer and an alignment layer on the internal surface, abutting the liquid crystal layer. The optical performance of an LCD depends on many design parameters, including the material properties of the liquid crystals, the electrode  
30 structure, the pixel patterning and proximity, the ON state and OFF state orientations of the liquid crystal molecules, the use and construction of the alignment layers, the optical properties of the reflective, anti-reflective, and light

blocking layers, etc. For example, while the liquid crystal molecules are nominally vertical to the inside surfaces of the silicon substrate and the cover glass, in actuality the surface adjacent molecules are oriented with a residual tilt of 1-2 degrees from the normal. If this residual tilt angle becomes larger, device contrast starts to suffer.

The “iron cross” illustration of Figure 6a also represents the nominal polarization response of an ideal VA LCD, as seen through crossed polarizers, assuming it has a negligible tilt angle. However, the net contrast provided by the modulation optical system can be degraded by various subtle effects within either the LCDs (large tilt angles, bias voltages for the OFF state, thermally induced stresses, and large incident angles (large NA’s)) or within the polarization devices, including the wire grid polarization beamsplitter (such as wire surface orientation, wire rotation, and large incident angles (large NA’s)). These effects can either cause the contrast to be generally reduced while the iron cross pattern 320 is retained, or cause the iron cross pattern 320 to be deformed into another extinction pattern (a “baseball” pattern 325 shown in Figure 6b, for example). In the case of modulation optical system 200, which partially comprises a wire grid pre-polarizer 230, a wire grid polarization beamsplitter 240, a vertically aligned LCD 210, and a wire grid polarization analyzer 270, the nominal system only provides ~600:1 contrast in the green at F/2.3, which is below specification. The system contrast can be enhanced, to meet and exceed specification, through the use of the appropriate compensators. Certainly polarization contrast can be potentially enhanced by making design changes to the actual polarization devices (the wire grid polarization beamsplitter and the LCDs) themselves. However, as it is not always possible or easy to alter the fundamental design, manufacturing, and performance limitations of these devices, alternate methods of improving contrast have been sought. In particular, the contrast performance of modulation optical system 200 has been enhanced with new polarization compensators developed specifically to work with wire grid polarizers, and with new polarization compensators developed specifically to work with the combination of vertically aligned LCDs and wire grid devices.

Compensators and polarizers are constructed from birefringent materials, which have multiple indices of refraction. Comparatively, isotropic media (such as glass) have a single index of refraction, and uniaxial media (such as liquid crystals) have two indices of refraction. Optical materials may have up to three principle indices of refraction. The materials with all three different refractive indices are called biaxial, and are uniquely specified by its principal indices  $n_{x_0}$ ,  $n_{y_0}$ ,  $n_{z_0}$ , and three orientational angles as shown in Figure 7a. Figure 7b shows a biaxial film with the axes of  $n_{x_0}$ ,  $n_{y_0}$ , and  $n_{z_0}$  aligned with x, y, and z axes, respectively. The materials with two equal principal refractive indices are called uni-axial materials. These two equal indices are ordinary index and referred as  $n_o$ . The other different refractive index is called an extraordinary index  $n_e$ . The axis of  $n_e$  is also referred to as an optical axis. Uniaxial materials are uniquely characterized by  $n_e$ ,  $n_o$ , and two angles describing the orientation of its optical axis. When all three principal indices are equal, the materials are called isotropic.

Light sees varying effective indices of refraction depending on the polarization direction of its electric field when traveling through a uniaxial or biaxial material, consequentially, a phase difference is introduced between two eigen-modes of the electric field. This phase difference varies with the propagation direction of light, so the transmission of the light varies with angle when uniaxial or biaxial materials are placed between two crossed polarizers. These phase differences translate into modifications of the local polarization orientations for rays traveling along paths other than along or parallel to the optical axis. In particular, a compensator modifies or conditions the local polarization orientations for rays at large polar angles, which also includes both oblique and skew rays. A liquid crystal material is typically a uniaxial material. When it is sandwiched between two substrates as in a liquid crystal display, its optic axis generally changes across the thickness depending on its anchoring at the substrates and the voltage applied across the thickness. A compensator is constructed with one or more uniaxial and/or biaxial films, which are designed to introduce angularly dependent phase differences in a way to offset the angle dependence of phase difference introduced by liquid crystals or other optics. As is

well known in the art, a uniaxial film with its optic axis parallel to the plane of the film is called a A-plate as shown in Figure 7c, while a uniaxial film with its optic axis perpendicular to the plane of the film is called a C-plate, as shown in Figure 7d. A uniaxial material with  $n_e$  greater than  $n_o$  is called a positively birefringent.

5 Likewise, a uniaxial material with  $n_e$  smaller than  $n_o$  is called negatively birefringent. Both A-plates and C-plates can be positive or negative depending on their  $n_e$  and  $n_o$ . A more sophisticated multi-layer compensator 400 has its optic axis or three principal index axes varying across its thickness, as in Figure 7e, where a stack of compensation films (birefringent layers 410a, 410b, and 410c)  
10 are used with a substrate 420 to assemble the complete compensator. A detailed discussed of stack compensation can be found in U.S. Patent No. 5,619,352 (Koch et al.). As is well known in art, C-plates can be fabricated by the use of uniaxially compressed polymers or casting acetate cellulose, while A-plates can be made by stretched polymer films such as polyvinyl alcohol or polycarbonate.

15 The combination of crossed wire grid polarizers (wire grid polarization beamsplitter 240, wire grid pre-polarizer 230, and wire grid polarization analyzer 270) in modulation optical system provides an excellent dark state for light traveling in the planes parallel or perpendicular to the wires. However, a maximum amount of light leakage occurs when light travels at a large  
20 polar angle (theta) away from the polarizer normal direction and 45/135 degree relative to the wires (Figure 5b shows the polar and azimuthal geometry for the polarizers). For example, with reference to Figure 6a, for the standard "iron cross" type extinction pattern, peak contrast along the axes can exceed 1,000:1, while contrast in the four quadrants located 45 degrees off the crossed coordinate  
25 axes falls off to 300:1 or less. Light transiting these angular regions, which includes skew rays, experiences less extinction than light closer to the axes. This loss of contrast from the quadrant rays and the skew rays can be significant for digital cinema projection, which again requires high optical system contrast (>2,000:1) and fast optics (<F/3.0).

30 Wire grid polarizers have been studied by the use of effective medium theory ("Generalized model for wire grid polarizers", Yeh, SPIE Vol. 307, (1981), pp.13-21). When the grating pitch (p) is much smaller than the

wavelength ( $\lambda$ ), the sub-wavelength grating can be approximately considered as an uni-axial film with effective refractive indices. Although effective medium theory is much easier to be implemented and provides a qualitative understanding of wire grid polarizers, it generally fails to obtain accurate results. It is especially true for calculation of very low transmission through crossed wire grid polarizers. The limitation of effective medium theory has been pointed out by Kihuta et al. ("Ability and limitation of effective medium theory for sub-wavelength gratings", Optical Review 2, (1995) pp.92-99). As a result, the wire grid polarizers have been modeled using the more exacting rigorous coupled wave analysis (RCWA) discussed in Kuta et al. ("Coupled-wave analysis of lamellar metal transmission gratings for the visible and the infrared", Kuta, et al., Journal of the Optical Society of America A, Vol. 12, (1995), pp.1118-1127). The results given in Figures 8a through 8i for wire grid polarizers are modeled using RCWA.

Figure 8a shows the theoretical transmission through crossed wire grid polarizers about normal incidence, and shows that the transmission at a polar angle of 20 deg. (F/1.5) and an azimuthal angle of 45 deg. is  $0.99 \times 10^{-3}$ , which is 2.5x larger than the transmission of  $0.4 \times 10^{-3}$  at a polar angle of 0 deg. For an even larger polar angle, such as 40 deg. (F/0.8), at an azimuthal angle of 45 deg., the transmission loss is much greater, with the value of  $5 \times 10^{-3}$ . The increased transmission translates into additional light leakage, and thus loss of contrast. For these calculations, the wire grid polarizers were modeled as aluminum wire structures, deposited on Corning glass 1737F, with a wire pitch of 144 nm ( $\sim \lambda/4$ ), a wire duty cycle of 0.45, and a wire height of 130 nm. The wire grid polarizer is modeled in the green at 550 nm, with the refractive index of Al being  $0.974 + i6.73$ , and the refractive index of Corning glass is 1.52. These parameters are used for Figure 8a through Figure 8i unless specified otherwise. As can be seen in Figure 8a, the maximum light leakage (reduced contrast) occurs at 45 degrees relative to the wire grid. Figure 8a can be understood with reference to the geometry of Figure 5b, which shows that for the normally incident beam, the relevant cone of light is described by an azimuthal sweep of  $0-180^\circ$  and a polar sweep of  $\sim 0-20^\circ$  (F/1.5). The plot of Figure 8a shows variations in transmission for crossed polarizers vs. azimuthal and polar angles, rather than the variations in contrast.



Polarization contrast can be difficult to model in a comprehensive way for a complex system like modulation optical system 200. However, contrast is approximately inversely proportional to the transmission for crossed polarizers, such that small changes in transmitted light can cause huge changes in system contrast. While Figures 8a-f also show significant off-angle transmission effects for slower beams (in particular at  $10^\circ$ , or F/2.9), the data will be consistently presented at  $20^\circ$  (F/1.5) for a more dramatic comparison.

Notably, the general behavior of crossed polarizers to suffer light leakage for oblique and skewed rays at large polar angles does not change substantially just by using better polarizers. For example, modeling has shown that even if the pitch of wire grid is much smaller than the wavelength of the light, such as  $1/100$ , a significant amount of light still leaks through two crossed wire grid polarizers at large polar angles. Figure 8b shows the transmission through crossed wire grid polarizers, where the pitch of the wire grid polarizers is  $5.5 \text{ nm}$  ( $\lambda/100$ ). Certainly the fine pitch  $\lambda/100$  device does show lower transmission than does the  $\lambda/4$  device ( $0.23 \times 10^{-3}$  vs.  $0.4 \times 10^{-3}$  at a polar angle of  $0^\circ$ ), and thus provides higher contrast (the theoretical contrast differences are much greater than  $2\times$  between  $\lambda/100$  and  $\lambda/4$  devices). In this case, the modeled  $\lambda/100$  device shows increased transmission (and thus light leakage) at a polar angle of  $20^\circ$  and an azimuthal angle of  $45^\circ$  of  $0.95 \times 10^{-3}$ , which is  $\sim 4\times$  larger than the transmission of  $0.23 \times 10^{-3}$  at a polar angle of  $0^\circ$ . At a polar angle of  $40^\circ$  degrees (and an azimuthal of  $45^\circ$  degrees), the transmission (light leakage) is  $10\times$  greater ( $9.7 \times 10^{-3}$ ). Thus, even for these  $\lambda/100$  wire grids, which are far finer than what is presently manufacturable, the off axis behavior is largely the same, although the theoretical extinction is greater.

Wire grid polarizers, which transmit the P-polarization as an extraordinary ray (E-type) and reflect the S-polarization as an ordinary ray (O-type), while only absorbing  $\sim 10\%$  of the incident light, cannot be accurately treated as a uniaxial film. By comparison, the standard sheet polarizer, which is manufactured by Polaroid Corporation, is similar to the wire grid polarizer in that it uses “wires” (iodine atoms imbedded in stretched PVA plastic), is actually a

significantly different device. First, the sub-wavelength “wires” ( $p \ll \lambda$ ) of the dye sheet polarizer are significantly smaller than wires of the visible wavelength wire grid polarizer ( $p \sim \lambda/4$ ). Moreover, the dye sheet polarizer is an O-type polarizer, which transmits the ordinary wave and absorbs (rather than reflects) the extraordinary wave. The standard dye sheet polarizer can be accurately modeled as a uniaxial film with an extraordinary index and an ordinary index. Optiva Inc. recently developed an E-type sheet polarizers based on supra-molecular lyotropic liquid crystalline material, which transmit the extraordinary wave and absorb the ordinary wave of incident light. (see Lazarev et al., “Low-leakage off-angle in E-polarizers”, Journal of the SID, vol. 9, (2001), pp.101-105). The Optiva polarizer is a sheet polarizer similar to the standard dye sheet polarizer, except that it is an E-type polarizer which transmits the extraordinary wave and absorbs (rather than reflects) the ordinary wave.

When two standard O-type dye sheet Polaroid polarizers are used in the crossed configuration, an iron cross pattern 320 (see Figure 6a) is also experienced. Light leaks through these conventional crossed sheet polarizers at obliquely incident angles with maximum leakage occurring at 45 degrees relative to the transmission or absorption axes of the sheet polarizers. Various compensators have been proposed to reduce light leakage through crossed O-type polarizers, as published by Chen et al. and in Uchida et al. (T. Ishinabe, T. Miyahita, and T. Uchida, “Novel Wide Viewing Angle Polarizer with High Achromaticity”, SID 2000 Digest, pgs. 1094-1097). According to Chen, a combination of uniaxial materials, an A-plate and a C-plate, dramatically reduces light leakage at off angle. One of its design requirements is that the optical axis of the A-plate should be parallel to the transmission axis of the adjacent polarizer. Uchida solves the same problem using two biaxial films to construct the compensator.

Although wire grid polarizers (E-type polarizer in transmission, O-type in reflection) and standard sheet polarizers (O-type in transmission, E-type absorption) are significantly different devices, benefit might be obtained by combining an existing compensator for a sheet polarizer with crossed wire grid polarizers. Figure 8c shows the transmission through crossed wire grid polarizers

paired with a prior art sheet polarizer compensator from Chen et al., which consists of a 137 nm A-plate and a 80 nm C-plate. For the case of a light beam at a polar angle of 20 deg. (F/1.5) and an azimuthal angle of 45 degrees, this compensator does provides significant improvement, reducing the transmission to  
5  $0.52 \times 10^{-3}$ , which represents about 30% more light leakage than the on-axis case for an un-compensated crossed polarizers ( $0.4 \times 10^{-3}$ ). However, at greater polar angles, such as 40 degrees (again, an azimuthal angle of 45 degrees) this compensator still allows substantially greater transmission, at a level of  $2.4 \times 10^{-3}$ , or  $\sim 6\times$  greater than the on-axis case. The pitch of the wire grid is again assumed  
10 to be 144 nm. Thus, while prior art sheet polarizer compensators can be used in combination with crossed wire grid polarizers to provide some polarization contrast improvement, there is yet room for further improvement.

Fortunately, it is possible to design compensators which are specifically optimized to work with wire grid polarizers and wire grid polarization  
15 beamsplitters, and which can be used to boost the contrast provided by modulation optical system 200. When wire grid polarizers are utilized as a polarizing beamsplitter, they first transmit light and then reflect light, or first reflect light and then transmit light. The angle at which light strikes the wire grid polarizer at the first time is generally different from the angle at which light does at the second  
20 time. The new compensators have been developed to minimizing light leakage through crossed wire grid polarizers at off angles within modulation optical system 200. Likewise, compensators have been developed which reduce light leakage through a wire grid polarizing beamsplitter.

As a first example, a polarization compensator was designed as a  
25 combination of an A-plate and C-plate, neither of which will affect the on-axis transmission while reducing the off-axis transmission. The designed compensator, which enhances the performance of crossed wire grid polarizers (wire grid pre-polarizer 230 and wire grid polarization analyzer 270 of Figure 3), uses a combination of two specific birefringent films, a +275 nm A-plate and a -  
30 60 nm C-plate. Figure 8d, which shows the total transmission through the combination of the crossed wire grid polarizers and this first example compensator, shows a broad change in the transmission response curves,

indicating significant transmitted light reductions as compared to Figure 8a. The transmission is below  $0.48 \times 10^{-3}$  for all polar angles up to 40 deg. ( $\sim 0.4 \times 10^{-3}$  at  $20^\circ$  polar angle), which is basically equal to the on-axis transmission for the uncompensated crossed wire grid polarizers ( $0.4 \times 10^{-3}$ ). In actuality, the compensator modifies or conditions the polarization orientations of the oblique and skew rays to improve their transmission through the crossed polarizers, thereby enhancing the contrast of the modulated beam. This optimized compensator for wire grid polarizers also provides significantly better performance than does the sheet polarizer compensator discussed previously. Notably, the optical axis of the A-plate for this wire grid polarizer compensator is perpendicular to the transmission axis of the adjacent polarizer. Whereas, by comparison, the prior art sheet polarizer compensator, as described by Chen et al., requires that the optical axis of the A-plate to be parallel to the transmission axis of the adjacent polarizer.

Although, this first example compensator design has significantly improved the performance of a modulation optical system 200 which uses crossed wire grid polarizers, where these wire grid devices have a relatively large pitch ( $p = 144 \text{ nm} \sim \lambda/4$ ), the same compensator design can improve the performance when wire grid devices with a smaller pitches are used. For example, Figure 8e shows the modeled performance of a fine pitch device ( $p = 5.5 \text{ nm} \sim \lambda/100$ ) with compensation, where the transmission at a polar angle of 40 deg. and an azimuthal angle of 45 deg. has dropped to  $0.24 \times 10^{-3}$  as compared to the prior uncompensated result of  $9.7 \times 10^{-3}$  shown in Figure 8b.

A second example compensator was designed for use with crossed wire grid polarizers, which also has a combination of an A-plate and a C-plate. In this case, the A-plate and C-plate both have positive birefringence, with retardations of 137 nm and 160 nm, respectively. Unlike the first example compensator, the optical axis of the A-plate for this compensator is parallel to the transmission axis of the adjacent polarizer. Figure 8f shows the improved transmission resulting from this compensator design, which is below  $0.46 \times 10^{-3}$  for all polar angles up to 20 degrees. However, at a polar angle of 40 deg. and an azimuthal angle of 45 deg. the transmission is only reduced to  $1.1 \times 10^{-3}$ . While

this design is not as good as the first example compensator design, particularly above 20 degree polar angle (see Figure 8d), the light leakage is still significantly reduced as compared to the un-compensated crossed polarizers (see Figure 8a). As before, this compensator can be inserted into a modified the modulation optical system 200 of Figure 10, as an added element, secondary compensator 265.

In Figure 10, which shows modified modulation optical system 200, the compensator used to optimize performance through the crossed wire grid polarizers (pre-polarizer 230 and analyzer 270) is located prior to analyzer 270, and is shown as secondary compensator 265. This same compensator could alternately be located just after wire grid pre-polarizer 230, as indicated by alternate secondary compensator 266 of Figure 10. As another alternative, part of a designed compensator for these crossed polarizers can be positioned as secondary compensator 265, while another portion is simultaneously provided as alternate secondary compensator 266. That is an unlikely scenario, as both the component count and mounting requirements are increased. It is also a requirement that the secondary compensator(s) 265 (and/or 266) be located in the optical path between wire grid pre-polarizer 230 and wire grid polarization analyzer 270. That means that secondary compensator 265 cannot, for example, be located after wire grid polarization analyzer 270.

Secondary compensator 265 can also be used in an unfolded optical system without a polarization beamsplitter, as shown in Figure 5c. In this case, transmitted polarized light exits wire grid pre-polarizer 230, passes through a spatial light modulator 210 (which is nominally a transmissive LCD), secondary compensator 265, and wire grid polarization analyzer 270. Alternately, the wire grid polarizer secondary compensator 265 can be located prior to the spatial light modulator 210 within modulation optical system 200. As shown in Figure 5c, the wire grid pre-polarizer 230 and wire grid polarization analyzer 270 are crossed, so that modulation optical system 200 is nominally in the Off state, and spatial light modulator 210 rotates light to transmit through the wire grid polarization analyzer 270 to provide On state light. It should be understood that the wire grid pre-polarizer 230 and wire grid polarization analyzer 270 can be aligned for nominal

open state transmission (not crossed), with the spatial light modulator 210 rotating light for the Off state.

Polarization response improvement can also be provided for the wire grid polarization beamsplitters, as well as for the wire grid polarizers. Figure 8g shows the combined transmission (product of the transmitted light and reflected light) through wire grid polarizing beamsplitters without polarization compensation, assuming that the spatial light modulator 210 is replaced with a perfect mirror. In this case, the incoming beam is incident on 45° tilted surface with a cone described by an azimuthal sweep of 0-180°, and a polar sweep of angles of ~0-40° (see Figure 5a), where the light falls within 0-15° polar angle for an F/2.0 beam. For example, Figure 8g. shows a combined transmission without polarization compensation of  $6.5 \times 10^{-2}$  at a polar angle of 30° and an azimuthal angle of 45°.

A third example compensator was designed, in this case to enhance the contrast provided by wire grid polarization beamsplitter 240, as used in the modulation optical system 200 of Figure 10 along with spatial light modulator 210 (VA LCD). This compensator example has a combination of an A-plate and a C-plate, having retardations of 90 nm and 320 nm (both with positive birefringence), respectively. Within the layered structure of the compensator, the A-plate is preferentially located closer to the wire grid polarization beamsplitter than the C-plate, which is closer to the LCD. The optical axis of A-plate is parallel to the transmission axis of the adjacent polarizer (perpendicular to the wires). Figure 8h shows the combined transmission through a wire grid polarizing beamsplitter used in combination with this compensator is reduced to  $2.7 \times 10^{-2}$  compared to  $6.5 \times 10^{-2}$  at a polar angle of 30 degrees in Figure 8g. Even at smaller polar angles, such as 15 or 20 degrees, the compensator reduces transmission (less leakage) by ~2x as compared to the un-compensated wire grid polarization beamsplitter. This compensator is shown in the modified modulation optical system 200 of Figure 10 as compensator 260, and is located between wire grid polarization beamsplitter 240 and liquid crystal spatial light modulator 210. This is the only acceptable location for this compensator within modulation optical system 200.

A fourth example compensator was designed, as with the last exemplary device, to enhance the combined transmission provided by wire grid polarization beamsplitter 240 used in the modulation optical system 200 of Figure 10 along with spatial light modulator 210 (VA LCD). This compensator is a  
5 combination of A-plate and C-plate having a retardation of 90 nm and -200 nm, respectively (positive and negative birefringence). The compensator of Figure 8i provides a smaller combined transmission, which is  $3.5 \times 10^{-2}$  compared to  $6.5 \times 10^{-2}$  in Figure 8g. Unlike the third example compensator, the optical axis of the A-plate for this compensator is perpendicular to the transmission axis of the adjacent  
10 polarizer (parallel to the wires), rather than parallel to the transmission axis (perpendicular to the wires). As before, this compensator is shown in the modified modulation optical system 200 of Figure 10 as compensator 260.

It should be emphasized that the prior art does not describe how to design a modulation optical system for a projection display using both LCDs and  
15 wire grid devices, which further has polarization compensators to boost contrast. Certainly, the actual exemplary compensators designed for use with the wire grid devices can have conventional structures and combinations of materials (such as polycarbonate or acetate) as have been previously described for other polarization devices. However, wire grid polarizers are distinctly different from the prior art  
20 devices (sheet polarizers and MacNeille prisms for example) in subtle and non-obvious ways, and therefore the design of the associated optimized compensators cannot be easily extrapolated from the prior compensator designs.

It is of course understood that various designs can achieve comparable performances as described above or even better. It is also understood  
25 that a single biaxial film can be used to replace the combination of A-plate and C-plate for any of these exemplary compensators. It should also be understood that the modeled compensators can be designed in reverse order, with the C-plate encountered before the A-plate, rather than the order of A-plate and then C-plate provided in the above examples. When the order is switched, the designed  
30 birefringence values likely change. It is also understood that additional A-plate and/or C-plate and/or biaxial films can be added to the combination of A-plate and C-plate for any of these exemplary compensators.

Certainly, as with the addition of any other optical component into a system, the usual concerns for providing the mounting and AR coatings for these compensators also apply. The compensators may be constructed with their birefringent films sandwiched between two glass substrates, with optical matching adhesives or gels holding the elements together. In that case, any glass to air surfaces should be AR coated. Alternately, the compensators can be integrated with the wire grid polarizers (wire grid pre-polarizer 230 and wire grid polarization analyzer 270) and mounted directly to the glass substrates of these components. That reduces the part count, the count of glass to air surface interactions, and the mounting issues. However, the compensator should be mounted to the flat glass surface of the wire grid device, and not to the surface with the wire grid coating.

Although the above examples are designed for a single wavelength at 550 nm, it should be understood that these examples function for all other wavelengths equally well as for 550 nm provided that the material of the compensator has a dispersion matched with wavelength. This means that ratio of the retardation/wavelength is substantially unchanged across all visible wavelengths.

It should also be understood that modulation optical system 200 can be constructed in a variety of combinations. As depicted in Figure 10, it includes wire grid pre-polarizer 230, wire grid polarization beamsplitter 240, wire grid polarization analyzer 270, compensator 260, secondary compensator 265, and alternate secondary compensator 266. However the system could be constructed with wire grid pre-polarizer 230, wire grid polarization beamsplitter 240, wire grid polarization analyzer 270, and compensator 260, with the secondary compensators left out. Likewise, the system could be constructed with wire grid polarization beamsplitter 240 and compensator 260, but with wire grid pre-polarizer 230 and wire grid polarization analyzer 270 as non-wire grid devices, and with the secondary compensators left out. Alternately again, the system could be constructed with wire grid pre-polarizer 230, wire grid polarization beamsplitter 240, wire grid polarization analyzer 270, and secondary compensator 265, but



with compensator 260 left out. Needless to say, yet other combinations of components are possible.

The overall contrast performance of modulation optical system 200 of Figure 10 can be enhanced not only by providing compensators which optimize the performance of the crossed wire grid polarizers or the wire grid polarization beamsplitter, but also which enhance the performance of the LCDs as seen through the wire grid polarization beamsplitter. By comparison, in the prior art, U.S. Patent No. 5,576,854 (Schmidt et al.) a compensator is described which optimizes for the VA LCD working in combination with a MacNeille beamsplitter. As disclosed in U.S. Patent No. 5,576,854, a  $0.27\lambda$  compensator is used, where  $0.25\lambda$ 's compensate for the MacNeille prism and  $0.02\lambda$ 's for birefringence in the counter electrode substrate. The counter electrode substrate is susceptible to thermal gradients that cause stresses within the substrate, which in turn cause localized birefringence. Even with carefully chosen materials for the substrate glass, such as SF-57 or fused silica, a small retardance, such as  $0.02\lambda$ 's was used to compensate for residual light leakages in the dark state from stress birefringence. When a vertical aligned LCD is in a non-active state without any voltage applied, the light leakage at on axis is small. However, in practice the dark state is a state with a non-zero voltage called as Voff. This voltage causes the liquid crystal to tilt down, and can significantly increase light leakage. Compensators have also been designed by others for example, U.S. Patent No. 5,298,199 (Hirose, et al.) to correct for this effect.

In the case of a vertically aligned LCD combined with a wire grid polarizing beamsplitter, the  $0.25\lambda$ 's retardance used in U.S. Patent No. 5,576,854 for the MacNeille type prism is not required. However, the residual  $0.02\lambda$ 's retardance ( $\sim 11$  nm), which is provided as an A-plate, may still be useful to correct to stress birefringence within the VA LCD, even with wire grid devices. In addition, a compensator optimized for a VA LCD may also include a negative C-plate when used in fast optical systems, including a digital cinema system operating at F/3.0 or below. Thus, preferred compensators for reflective VA LCD's used in combination with wire grid polarizers comprise a negative C-plate

and a positive A-plate. The negative C-plate is preferred to have same amount of retardation as the liquid crystal (+233 nm for example), but with opposite sign, to correct the viewing angle dependence of the liquid crystal. This viewing angle dependent retardation present in the liquid crystal is typically ~160-250 nm.

5                   As an example, Figure 9a shows the contrast contour plot for light reflected off of an ideal VA LCD through crossed polarizers in the Off state. This corresponds to the “iron cross” pattern 320 of Figure 6a, with minimal light along the optical axis (center of the spherical pattern) and along the directions parallel or perpendicular to the transmission axis of the crossed polarizers. However, as the  
10   iron cross pattern 320 shows, some leakage light can be expected in the four quadrants. Figure 9b shows contrast contour plot for light reflected off a VA LCD with 10 nm residual retardation from induced birefringence in the substrate, which corresponds to the baseball pattern 325 of Figure 6b. Unfortunately, when this baseball pattern 325 occurs, leakage light into the projection system is  
15   significantly increased, and the contrast is reduced. Figure 9c shows contrast contour plot for a VA LCD with proper compensators (-233 nm C-plate) designed according to the present invention inserted at the above discussed locations. The 1000:1 iso-contrast curve extends to more than 13° of polar angle. This compensator can be inserted into modified optical modulation system 200 of  
20   Figure 10, immediately prior to the LCD 210, as compensator 260.

                  In actuality, the compensators for the wire grid polarization beamsplitter 240 and the LCD 210 are co-located between these two components, and can be combined into one packaged compensator device. The exemplary compensator for the wire grid polarization beamsplitter 240 corresponding to  
25   Figure 8h used a combination of an A-plate and a C-plate having a retardation of 90 nm and 320 nm. By comparison, the vertically aligned LCD has a retardation of ~233 nm, and requires a C-plate with a -233 nm retardation for correction. When these two C-plate designs are combined, the remaining C-plate has only ~87 nm retardance. Thus, the cancellation between the compensator and the LCD  
30   significantly decreases the amount of additional retardance needed. The combined compensator 260 then comprises the 11 nm A-plate for the VA LCD (0.02λ's compensation), the 87 nm C-plate, and the 90 nm A-plate for the wire

grid polarization beamsplitter 240 in sequential order, with the 11 nm A-plate located closest to the LCD 210. The two A-plates cannot be simply combined, as the 11 nm A-plate needs to be rotatable, while the 90 nm A-plate has a fixed orientation relative to the sub-wavelength wires 250. Thus, what is provided is an apparatus and method for achieving high levels of contrast by using a wire grid polarization beamsplitter with a compensator for minimizing leakage light in the pixel black (OFF) state for a VA LCD.

Figure 4 shows a graph 310 of the compensated contrast that relates system contrast to the relative F# for a modulation optical system comprising a VA LCD, wire grid polarizers, a wire grid polarization beamsplitter, and a compensator, which correct for the unwanted P polarization in returning modulated beam. In this case, a customized version of compensator 260 is used. Notably, although use of a compensator can actually reduce CR at higher F# values, the compensator improves contrast at low values, below approximately F/4.0. Note that compensated contrast 310 may not always be better, because compensators can be complex structures, which can suffer undesired reflections and defects.

It should be understood that the polarization compensation concepts developed within this application for optimizing the polarization performance of wire grid polarizer devices could be used in modulation optical systems which have spatial light modulators other than vertically aligned LCDs. For example, spatial light modulator 210 could also be a 60 degree twisted nematic LCD, a PLZT modulator, or some other polarization rotating modulator.

Thus far, the discussion of the use of polarization compensators in a projection system using wire grid polarizers generally, and a wire grid polarization beamsplitter 240 specifically, in combination with a LCD type spatial light modulator 210, has been directed largely at the design and performance of the compensators. Specifically, the goal has been to maximize the frame sequential polarization contrast between the modulated and un-modulated light, by optimizing the variable polarization response vs. angle (for example, see Figures 9a-c). However, as shown in Figure 11, which shows a contrast pattern 500 with a high contrast region 510 in the center. Contrast pattern 500 can be observed on

screen in a projected dark state image, where for example, the high contrast region 510 may exhibit 2,000:1 contrast, while the low contrast regions 520 may only have 800:1 contrast. Contrast pattern 500 is illustrative only, and it should be understood that the low contrast regions may not be experienced symmetrically as shown, nor fall to identical low contrast values.

Spatial contrast variation at the screen can originate with many sources in the system, including LCD variation, compensator retardance variation, non-telecentric light propagation through the polarization optics, and stress birefringence in the polarization sensitive optics. Other non-polarization related factors, such as ghost reflections, surface reflections, and surface scatter, can affect contrast (both ANSI in-frame contrast and frame sequential contrast) in a spatially variant manner. However, a system with only 150:1 ANSI in-frame contrast can exhibit 2,000:1 frame sequential contrast, as well as a spatially variant frame sequential contrast pattern 500, such as depicted in Figure 11. Assuming that the optical system is telecentric, and also that stress birefringence in the optics (such as the polarization beamsplitter and the recombination prism) is minimized, then any frame sequential contrast spatial variation will likely originate in the polarization compensators and/or in the LCD panels.

The spatial contrast variation represented in Figure 11 represents a spatial variation in the modulated ON state light combined with a spatial variation of the leakage light, which is light of the orthogonal polarization state to the modulated ON state light. Fundamentally, the spatial variation in polarization rotations occurs because the light does not encounter uniform retardances across the image field. It is generally understood that retardance is the delay of one polarization relative to the orthogonal polarization, where the delay translates into a phase change  $\Delta\phi$  in the polarization of the incoming light. The phase change  $\Delta\phi$  can be calculated as

$$\Delta\phi = 2 \pi * t * \Delta n / \lambda,$$

where ( $\Delta n$ ) is the index change ( $\Delta n = n_{||} - n_{\perp}$ ) (intrinsic birefringence) provided by the structure and ( $t$ ) is the thickness of the structure. Retardance is the phase

change  $\Delta\phi$  expressed as distance; for example a  $\pi/2$  phase change  $\Delta\phi$  corresponds to a quarter wave  $\lambda/4$  retardance, which at 550 nm equals  $\sim 138$  nm retardance.

Bulk crystalline materials, such as calcite, have an intrinsic birefringence, as defined above. Liquid crystalline materials also are intrinsically birefringent on a molecular level. However, the actual retardance experienced is dependent on the liquid crystal composition, the orientation (tilt and twist) of the LC molecules within a cell, and the applied voltage across the cell, as well as the polarization state of the incident light. Thus, the in-plane birefringence and retardance can be spatially variant through the thickness of the cell, as well as across the length and width of the cell. In the case that a display sees nominally uniform drive voltages, the birefringence and retardance can be considered to be uniform across the length and width of the cell (at least locally), and the variation through the thickness of the cell will remain. The cell can then be approximated by an effective birefringence ( $\Delta n_{\text{eff}} = n_x - n_y$ ) and an effective retardance

$$\Delta R = t * \Delta n_{\text{eff}} .$$

The retardance of the LC material is specified by both the magnitude of the refractive indices ( $n_x, n_y$ ) and their relative orientation (the slow axis of the material corresponds to the larger index). Although polarization compensators can be constructed with bulk intrinsic birefringent materials, or with form birefringent structures, they can also be made with liquid crystal polymer type materials that exhibit local variations in both refractive index and axial orientation. In the case that liquid crystal polymers are used to fabricate the compensator, the effective retardance depends on both the magnitude of the fast and slow axes refractive indices, as well as their relative orientation.

As discussed previously, compensators can comprise a series of stretched polymer films assembled into a stack assembled onto a substrate (see Figure 7e) with intervening layers of low stress adhesive to hold the structure together. In the particular instance of a compensator constructed with stretched polymer sheets, obtaining small amounts of in-plane (XY) retardance can be difficult, because the mechanical stretching process is uneven. For example, a multi-layer compensator that was constructed to provide a nominal 10.5 nm in-plane retardance actually was spatially variant, with retardances ranging from  $\sim 9.0$

to 12.0 nm (+/- 15%). However, polarization compensators can be fabricated by a variety of means, with potentially less variation. As an example, it has been reported that liquid crystal polymer compensation layers can be spun coat onto an alignment layer (formed on a substrate), such that the retardation values can be controlled within 3% accuracy. Compensators can also be constructed using optical coating, photo-lithographic, and laser etching fabrication technologies to form robust inorganic structures with much finer control of retardance uniformity. For example, compensators can be made as an optical thin film coating (see for example, U.S. Patent No. 5,196,953 (P. Yeh)) or as an anisotropic form birefringent optical structure.

The spatial retardance variations present in LCDs can be at least comparable (+/- 15%) to the largest changes cited above for the compensators. However, as LCDs are much more complicated structures, it is much more difficult to control or minimize the spatial variation of retardance within a LCD panel than it is in a compensator. Retardance variation in LCD's can be caused by a multitude of sources, including cell gap thickness variation, variations in the LC pre-tilt angle, index and thickness variations in the dielectric stacks of the internal anti-reflection coatings, and voltage noise from variations in the underlying CMOS circuitry. Accordingly, improved performance could be realized in a projector by providing a polarization compensator with a patterned retardance that corrects for the retardance variation of the associated spatial light modulator (LCD).

Certainly patterned retarders or compensators have been described in the prior art. U.S. Patent No. 5,548,427 (May) shows a spatially variant patterned retarder, comprising regions of alternately oriented retardances. Other examples include U.S. Patent No. 5,499,126 (Abileah et al.), which provides color tuned retarders that are aligned with RGB LCD sub-pixels, U.S. Patent No. 6,496,287 (Seiberle et al.) which provides a pattern of spatially variant retarders for counterfeit protection, and U.S. Patent No. 6,496,239 (Seiberle) which provides a patterned retarder mask useful for making other patterned retarders. As another example, the paper "Novel High Performance Transreflective LCD with a Patterned Retarder" by S.J. Roosendaal et al., and published in the SID 03 Digest

(pgs. 78-81) describes a patterned retarder that provides different retardances for the transmissive and reflective portions of a transreflective LCD pixel. The fabrication of the type of patterned retarders described in Roosendaal et al. and in Seiberle '239 are described in some detail in two related papers; "Technologies  
5 Towards Patterned Optical Foils" by B. van der Zande et al. (published in the SID 03 Digest, pgs. 194-197) and in "Photo-Aligned Anisotropic Optical Thin Films" by H. Seiberle et al. (published in the SID 03 Digest, pgs. 1162-1165). Both of these references describe the use of polarized UV light to expose a photo-alignment layer, which is in turn coated with a liquid crystal polymer, to form the  
10 patterned retarders. Notably, this prior art does not describe the use or fabrication of a patterned retarder that is fabricated to have a spatially variant retardance that compensates for the spatially variant retardance of a spatial light modulator (LCD). Moreover, the prior art does not describe the use of a spatially variant retarder/compensator that is used in combination with an LCD, and in further  
15 combination with wire grid polarizers, such that uniform contrast (gray levels and black) can result with each pixel nominally driven to identical code values. Finally, the prior art does not describe the fabrication of such a patterned compensator with other than UV exposing light.

An exemplary exposure system 530 is shown in Figure 12, which is  
20 provided to support the fabrication of a patterned compensator 550. Accordingly, spatial light modulator (LCD) 210 is illuminated with an illumination light beam, which can be polarized by pre-polarizer 230 and a wire grid polarization beamsplitter 240 (nominally both wire grid polarizers). Polarized light is then incident on LCD 210, which is electrically driven on a per pixel basis to identical  
25 code values for a nominally uniform output (nominally a mid-level gray). The modulated light reflected off the LCD 210 is separated from the greater portion of the unmodulated light by the wire grid polarization beamsplitter 240. The modulated image bearing light 290 is then directed to the wire grid polarization analyzer 270, which can also be a wire grid polarizer, where further off state  
30 leakage light is removed. Wire grid polarization analyzer 270 can be an optional component. Imaging relay lens 540, which should be nominally telecentric in both object and image space, provides a real image of the LCD 210 to a plane

where the patterned compensator 550 is located. Assuming the patterned compensator 550 is to be placed in close proximity to the LCD 210, then imaging relay lens 540 operates at 1x magnification.

Assuming the patterned compensator 550 is to be fabricated with  
5 liquid crystal polymer materials, in a fashion similar to that described in the Seiberle et al. paper, then the nominal process begins with locating a compensator substrate the exposure system 530. This substrate (not shown) is pre-coated with the light sensitive (polymer) photo-alignment layer. An image is then projected onto the patterned compensator 550, having a spatially variant contrast pattern  
10 500, of the sort depicted generally in Figure 11, so as to impress the compensator with a pattern corresponding to the spatially variant retardance of the modulator. As a function of position, the incident light varies both in intensity and polarization orientation. In accordance with the type of polymer used for the photo-alignment, the alignment layer orientation can be determined on localized  
15 basis by either director patterning or in-situ patterned photo-polymerization (patterning birefringence ( $\Delta n$ ) or thickness), where the polarization orientation of the incident light determines the photo-alignment.

The illumination light beam 220 directed at LCD 210 is preferably visible light, rather than UV light. To begin with, most types of LCDs are  
20 susceptible to damage when exposed to UV light. Additionally, to map the visible light response of the LCD 210 to the patterned compensator 550, visible illumination light should be used. Moreover, better results can be obtained if the illumination light beam is filtered to a color spectra (red for example) similar to the color spectra that will be directed onto a given LCD 210 when that LCD is  
25 mounted into the working system. To enable this, the polymer materials used to form the alignment layer can be enhanced with visible wavelength sensitive polymer photo-initiators. Note that the exposure system can also be provided with its own polarization compensator 260, optimally located between the wire grid polarization beamsplitter 240 and the test cell (LCD 210). For example, this  
30 compensator may provide C-plate compensation to correct for the angular response of the LCD and/or the polarization beamsplitter. This compensator may also provide in-plane (A-plate) compensation, but the provided in-plane



retardance is preferably very uniform, so that the retardance variations of the LCD 210 are not masked. Once the photo-alignment is completed, the patterned compensator 550 is nominally removed from the exposure system 530, and spun coat with liquid crystal polymers to form the actual retardation layer having the  
5 desired spatially variant retardance. Typically thereafter, the retardance imparted into a liquid crystal polymer layer is fixed by UV exposure.

In accordance with the present invention, it is intended that patterned compensator 550 have a spatially variant retardance that correlates with the spatially variant retardance of the LCD 210, such that a level or uniform  
10 retardance results when the two are used in combination. In the prior discussion, the fabrication of a patterned compensator 550 that utilizes liquid crystal polymers was discussed in some detail. In that case the effective retardance at any given position is a function of both the magnitude of the refractive indices ( $n_x$ ,  $n_y$ ) and their orientation (fast axis and slow axis). Patterned compensator 550 can have a  
15 spatially variant effective retardance, wherein the localized effective retardances are negative. The intent then is that the negative retardance is at its greatest magnitude where the LCD 210 has its greatest positive retardance, and the negative retardance has minimum magnitude where the LCD 210 has its minimum retardance, such that in combination, a uniform retardance is provided. Patterned  
20 compensator 550 can also have a spatially variant retardance comprising positive retardances, where there is less retardance where the LCD 210 has more retardance, and visa-versa, such that a uniform retardance is provided. For best results, patterned compensator 550 is nominally matched with the specific LCD 210 that was used in its fabrication in the exposure system. Moreover, for  
25 patterned compensator 550 to be effective, the spatially variant retardance of the associated LCD should be minimally time variant. Although Figure 12 shows and exposure system 530 constructed to facilitate the correction of a reflective spatial light modulator (LCD) 210, it should be understood that this system can be altered to operate with a transmissive polarization modulator as well. In that case, the  
30 patterned compensator 550 can be placed immediately after the LCD 210 during this patterning fabrication step for the compensator, thereby eliminating the need for imaging relay lens 540 as part of the exposure system 530.

It should then be understood that patterned compensator 550 is ultimately placed into a modulation optical system 200 (such as in Figure 3), nominally in close proximity to the matching LCD 210. As patterned compensator 550 will typically provide correction for slowly varying spatial changes in retardance, the registration of compensator 550 to the LCD 210 should not be super critical. Patterned compensator 550 can be incorporated into a compensator 260, where it may be supplemented by other A-plate and C-plate type compensators as necessary. The patterned compensator 550 is described herein as a device nominally made with liquid crystal polymers. Experimental data has been published in the previously cited paper by Seiberle et al. that shows that the birefringence of a liquid crystal polymer type polarization compensator is stable under high light exposure ( $3 \text{ W/cm}^2$  for over at least 9,000 hours). Nonetheless, for robust operation of polarization compensators, including the patterned compensator of the present invention, inorganic compensators (such as dichroic and form birefringent devices) would be favored due to their insensitivity to high thermal loads, stressful ambient environments, and UV light exposure.

The invention has been described in detail with particular reference to certain preferred embodiments thereof, but it will be understood that variations and modifications can be effected within the scope of the invention as described above, and as noted in the appended claims, by a person of ordinary skill in the art without departing from the scope of the invention.

## **PARTS LIST**

- 10. Digital projection apparatus
- 15. Light source
- 20. Illumination optics
- 40. Modulation optical system
- 45. Pre-polarizer
- 50. Wire grid polarization beamsplitter
- 55. Spatial light modulator
- 60. Polarization analyzer
- 70. Projection optics
- 75. Display surface
- 100. Wire grid polarizer
- 110. Conductive electrodes or wires
- 120. Dielectric substrate
- 130. Beam of light
- 132. Light Source
- 140. Reflected light beam
- 150. Transmitted light beam
- 200. Modulation optical system
- 210. Spatial light modulator (LCD)
- 220. Illumination light beam
- 225. Condensor
- 230. Wire grid pre-polarizer
- 240. Wire grid polarization beamsplitter
- 245. Dielectric substrate
- 250. Sub-wavelength wires
- 260. Compensator
- 265. Secondary compensator
- 266. Alternate secondary compensator
- 270. Wire grid polarization analyzer
- 275. Optical axis
- 285. Projection lens

- 280. Recombination prism
- 290. Modulated image-bearing light beam
- 300. System contrast
- 310. Graph
- 320. Iron Cross pattern
- 325. Baseball pattern
- 350. Pre-polarized beam
- 355. Transmitted beam
- 360. Modulated beam
- 365. Leakage light
- 370. Transmitted light
- 400. Multi-layer compensator
- 410a. Birefringent layers
- 410b. Birefringent layers
- 410c. Birefringent layers
- 420. Substrate
- 500. Contrast pattern
- 510. High contrast region
- 520. Low contrast region
- 530. Exposure system
- 540. Imaging relay lens
- 550. Patterned compensator